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**Response under 37 C.F.R. §1.116
Expedited Procedure
Group Art Unit 1712**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

KOZAWA et al.

Attorney Docket No: 100021-00065

Application No. 10/005,347

Art Unit: 1712

Filed: December 7, 2001

Examiner: K. Peng

For: SILICON-CONTAINING POLYMER, PROCESS FOR ITS PRODUCTION,
RESIST COMPOSITION EMPLOYING IT, PATTERN-FORMING METHOD AND
ELECTRONIC DEVICE FABRICATION METHOD

AMENDMENT AND RESPONSE UNDER 37 C.F.R. § 1.116

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Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

December 20, 2005

Sir:

This paper is filed in response to the final Office Action dated October 12, 2005, in connection with the above-identified application. Applicants respectfully request reconsideration and withdrawal of the rejections in view of the following amendments and remarks.

Amendment to the claims begin at page 2.

The **Remarks** begin at page 4.